
Oxidative Removal of Acetal Protection by the Action of $KHSO_5$ and $AlCl_3$ under Mild Heterogeneous Conditions*

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Protection [1] and deprotection [2] of carbonyl functionalities are key problems in organic chemistry. Numerous methods for removal of acetal protection are known. These are based mostly on acid-hydrolysis of the acetal moiety in aqueous medium [3]. Less common nonaqueous procedures utilize phosphorus triodide and diphosphorus tetraiodide [4], iodotrimethylsilane [5], chlorotrimethylsilane-sodium iodide [6], K10 montmorillonite [7], cobalt and manganese salts in the presence of oxygen [8], cerium(III) chloride [9], triphenylphosphine and CBr₄ [10], as well as oxidative systems, e.g. cerium ammonium nitrate [11], $Fe(NO_3)_3 \cdot 1.5N_2O_4$ [2], and $Cu(NO_3)_2 \cdot$ N₂O₄ [2]. We recently showed that heterogeneous systems are considerably more advantageous than homogeneous, for they are characterized by experimental simplicity, mild reaction conditions, and minimal wastes [12–17]. To our knowledge, Oxone (potassium peroxymonosulfate, KHSO₄·2KHSO₅· K_2SO_4 , p K_a ~1) is a widely used oxidant [18] which has never been applied to deprotect acetals.

In the present work various acetals (compounds Ia-Ik, see table) were subjected to deacetalization in the presence of Oxone and AlCl₃ in acetonitrile under reflux. According to the TLC data, the conversion of the initial acetal and the yield of the corresponding carbonyl compound were quantitative.

Deacetalization of compounds I was carried out in various solvents, such as acetonitrile, tetrahydrofuran, and methylene chloride. The most appropriate solvent was acetonitrile. We also examined the possibility of catalytic action of Oxone and AlCl₃ or at least

of using them in smaller than stoichiometric amounts. However, high yields of carbonyl compounds were obtained only when the ratio Oxone: AlCl₃: substrate was 1:3.8:6. Thus we have found that Oxone is an effective reagent ensuring fast removal of acetal protection.

$$R^3-O$$
 R^1
 R^4-O
 R^2
 R^2
 R^3-O
 R^2
 R^3-O
 R^3
 R^4-O
 R^2
 R^3-O
 R^3
 R^4-O
 R^3

Carbonyl compounds, ethylene glycol, aluminum chloride, and acetonitrile were purchased from Fluka, Merck, and Aldrich. Commercial potassium peroxymonosulfate was used (KHSO₄·2KHSO₅·K₂SO₄, from Merck). Acetals and 5,5-bis(hydroxymethyl)-2-norbornene were synthesized by the procedure described by us in [1]. The deacetalization products were identified by comparing their spectral (IR and ¹H NMR) and TLC data and physical properties with those of authentic samples.

Deacetalization of compound Ig to 4-hydroxy-3-methoxybenzaldehyde (typical procedure). A mixture of 0.07 g (0.25 mmol) of compound **Ig**, 0.3 g of Oxone, and 0.2 g of AlCl₃ in 5 ml of acetonitrile was refluxed for 60 min. The precipitate was filtered off and washed with methylene chloride, and the filtrate was evaporated under reduced pressure. Addition of ethanol and water to the residue gave 4-nitrobenzaldehyde in quantitative yield.

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Deacetalization with Oxone and AlCl₃ in acetonitrile

Comp.	Formula	Product	Comp.	Formula	Product
Ia	Me O O	COMe	Ig	MeO O O O	меО СНО
Ib	H O O	Ме	Ih	HO O	НО
Ic	O_2N	CHO CO	Ii	O ₂ N Me	COMe O ₂ N
Id	но	НО	Ij	CI	СНО
Ie	CH(OMe) ₂	СНО	Ik	H O	СНО
If	O ₂ N O	CHO CO		Br	Br

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